



INTERNATIONAL
GEMOLOGICAL
INSTITUTE

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LABORATORY GROWN DIAMOND REPORT

January 9, 2026

IGI Report Number

LG764635644

Description

LABORATORY GROWN DIAMOND

Shape and Cutting Style

CUT CORNERED RECTANGULAR
MODIFIED BRILLIANT

Measurements

11.07 X 7.97 X 5.21 MM

GRADING RESULTS

Carat Weight

4.03 CARATS

Color Grade

F

Clarity Grade

VVS 2

ADDITIONAL GRADING INFORMATION

Polish

VERY GOOD

Symmetry

EXCELLENT

Fluorescence

NONE

Inscription(s)

 LG764635644

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process.
Type IIa

PROPORTIONS

Thin

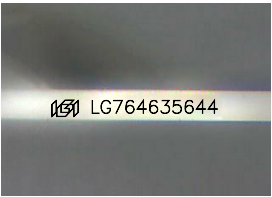
12%

52%

67%

65.4%

Pointed



Sample Image Used

COLOR

D

E

F

G

H

I

J

Faint

Very Light

Light

CLARITY

FL

IF

VVS¹⁻²

VS¹⁻²

SI¹⁻²

I¹⁻³

Flawless

Internally Flawless

Very Very Slightly Included

Very Slightly Included

Slightly Included

Included





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